IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Filing Date April 13, 1998 Inventor Pai-Hung Pan Assignee Micron Technology, Inc. Examiner Trinh, Michael Semiconductor Processing Methods of Forming a Conductive Gate and Line

INFORMATION DISCLOSURE STATEMENT

To:

Assistant Commissioner for Patents

Washington, D.C. 20231

From:

Jennifer J. Taylor, Ph.D. (Tel. 509-624-4276; Fax 509-838-3424)

Wells St. John P.S.

601 W. First Avenue, Suite 1300

Spokane, WA 99201-3828

Dear Sir:

The Examiner's attention is directed to the references which are listed on the attached Form PTO-1449 and copies of which are attached.

Citation of these references is respectfully requested.

Respectfully submitted,

Taylor. Ph.D

Jennifer J. Taylo Reg. No. 48,711